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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/688,867	10/17/2003	Francesco Stellacci	P-8698-US	9441
	7590 04/29/200 dek Latzer, LLP	EXAMINER		
1500 Broadway			YANG, NELSON C	
	12th Floor New York, NY 10036		ART UNIT	PAPER NUMBER
			1641	
			MAIL DATE	DELIVERY MODE
			04/29/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)		
	10/688,867	STELLACCI ET AL.		
Office Action Summary	Examiner	Art Unit		
	Nelson Yang	1641		
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address		
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w. - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim vill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	lely filed the mailing date of this communication. (35 U.S.C. § 133).		
Status				
Responsive to communication(s) filed on 14 Fe This action is FINAL. 2b) ☐ This Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro			
Disposition of Claims				
4) ☐ Claim(s) See Continuation Sheet is/are pending 4a) Of the above claim(s) 11,112,145,146,177-5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1,2,40,49,50,52,57,58,97,106,107 and 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	<u>180,182,183,215 and 216</u> is/are v <u>d 109</u> is/are rejected.	vithdrawn from consideration.		
Application Papers				
9) ☐ The specification is objected to by the Examiner 10) ☒ The drawing(s) filed on 17 October 2003 is/are: Applicant may not request that any objection to the ore Replacement drawing sheet(s) including the correction of the orection of	a)⊠ accepted or b)⊡ objected drawing(s) be held in abeyance. See on is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).		
Priority under 35 U.S.C. § 119				
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 				
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 1/30/04, 12/05/07.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ite		

Continuation of Disposition of Claims: Claims pending in the application are 1,2,40,49,50,52,57,58,97,106,107,109,111,112,145,146,177-180,182,183,215 and 216.

Art Unit: 1641

DETAILED ACTION

Election/Restrictions

1. Applicant's election without traverse of in the reply filed on February 14, 2008 is acknowledged.

2. Claims 11, 112, 145, 146, 177-180, 182, 183, 215, and 216 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on February 14, 2008.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 1, 2, 49, 50, 52, 57, 58, 106, 107, 109 are rejected under 35 U.S.C. 102(b) as being anticipated by Guire et al. [US 6,514,768].

With respect to claim 1, Guire et al. teach providing a master array having a support surface, immobilizing a plurality of oligonucleotides on the master array support surface, hybridizing multi-ligand conjugates with the oligonucleotides on the master array support surface, providing an assay array support surface, and disassociating the first binding domains from the master array support that permits the conjugates to remain upon the assay support surface (column 17, line 40 – column 18, line 25).

Art Unit: 1641

5. With respect to claim 2, Guire et al. teach that the multi-ligand conjugates contain a plurality of active domains (exposed functionality) (column 13, lines 22-28).

- 6. With respect to claim 49, Guire et al. teach an embodiment where portions of the second substrate are free of the multi-ligand components (see fig. 1A).
- 7. With respect to claims 50, 52, Guire et al. teach that the assay arrays may then be used as master arrays to form corresponding assays arrays by the same process (column 18, lines 55-63). Guire et al. teach passivating the surface of the assay array prior to and/or after exposure to the binding partner, such as with a surfactant (column 17, lines 1-5) or using wet chemical etching procedures to etch the substrate (column 21, lines 70-11). Guire et al. further teach washing excess conjugates from the surface of the substrate (column 21, liens 30-35), which would uncover portions of the substrate that are not part of the pattern.
- 8. With respect to claim 57, Guire et al. teach providing a master array having a support surface, immobilizing a plurality of oligonucleotides on the master array support surface, hybridizing multi-ligand conjugates with the oligonucleotides on the master array support surface, providing an assay array support surface, and disassociating the first binding domains from the master array support that permits the conjugates to remain upon the assay support surface (column 17, line 40 column 18, line 25). Guire et al. further teach that the multi-ligand conjugates contain a plurality of active domains (exposed functionality) (column 13, lines 22-28). Guire et al. teach that the assay arrays may then be used as master arrays to form corresponding assays arrays by the same process (column 18, lines 55-63).
- 9. With respect to claim 58, Guire et al. teach that the multi-ligand conjugates contain a plurality of active domains (exposed functionality) (column 13, lines 22-28).

Art Unit: 1641

would also be free of molecules.

10. With respect to claim 106, Guire et al. teach an embodiment where portions of the second substrate are free of the multi-ligand components (see fig. 1A). Therefore, since the pattern on the third substrate is formed by the same process as the second, portions of the third substrate

11. With respect to claims 107, 109, Guire et al. teach that the assay arrays may then be used as master arrays to form corresponding assays arrays by the same process (column 18, lines 55-63). Guire et al. teach passivating the surface of the assay array prior to and/or after exposure to the binding partner, such as with a surfactant (column 17, lines 1-5) or using wet chemical etching procedures to etch the substrate (column 21, lines 70-11). Guire et al. further teach washing excess conjugates from the surface of the substrate (column 21, liens 30-35), which would uncover portions of the substrate that are not part of the pattern.

Claim Rejections - 35 USC § 103

- 12. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 13. Claims 40 and 97 are rejected under 35 U.S.C. 103(a) as being unpatentable over Guire et al. [US 6,514,768] in view of Aksay et al. [US 2001/0023024].

With respect to claims 40, 97, Guire et al. teach providing a master array having a support surface that may be metal (column 7, lines 53-58) to form a pattern (column 3, lines 60-65), immobilizing a plurality of oligonucleotides on the master array support surface, hybridizing

multi-ligand conjugates with the oligonucleotides on the master array support surface, providing an assay array support surface, and disassociating the first binding domains from the master array support that permits the conjugates to remain upon the assay support surface (column 17, line 40 – column 18, line 25). Guire et al. fail to teach that the patterning is performed using electron beam lithography on a metal surface.

Aksay et al. teach using electron beam lithography to form patterns on arrays (para. 0080) and further teach that this allow for thinner structures to be formed.

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to have used electron beam lithography to form the patterns in the master array of Guire et al., as suggested by Aksay et al., in order to form small patterns, thus decreasing the size of the array formed.

Conclusion

- 14. No claims are allowed.
- 15. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nelson Yang whose telephone number is (571)272-0826. The examiner can normally be reached on 8:30-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Long V. Le can be reached on (571)272-0823. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Art Unit: 1641

16. Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

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like assistance from a USPTO Customer Service Representative or access to the automated

information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Nelson Yang/

Patent Examiner, Art Unit 1641